

## EAST Search History

S12 7	0	(metal adj foil)and ((coat\$3) with bath with voltage with heating)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2006/04/02 11:30
S12 8	9	(metal) and ((coat\$3) with bath with voltage with heating)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2006/04/02 12:58
S12 9	1	("3867166").PN.	US-PGPUB; USPAT	OR	OFF	2006/04/02 13:14
S13 1	0	( MESH ADJ SIEVE) WITH "200" WITH MILL WITH COATING	USPAT; EPO; JPO; DERWENT	OR	ON	2006/04/02 13:15
S13 2	11	( MESH ADJ SIEVE) WITH MILL WITH COATING	USPAT; EPO; JPO; DERWENT	OR	ON	2006/04/02 13:16
S13 3	0	( MESH ADJ SIEVE) WITH OPENING WITH DIAMETER WITH MILL WITH COATING	USPAT; EPO; JPO; DERWENT	OR	ON	2006/04/02 13:17
S13 4	1	( MESH ADJ SIEVE) WITH OPENING WITH DIAMETER WITH MILL	USPAT; EPO; JPO; DERWENT	OR	ON	2006/04/02 13:18
S13 5	0	( "200" ADJ MESH ADJ SIEVE) WITH OPENING WITH DIAMETER WITH MILL	USPAT; EPO; JPO; DERWENT	OR	ON	2006/04/02 13:18
S13 6	2	( "200" ADJ MESH ADJ SIEVE) WITH OPENING WITH DIAMETER	USPAT; EPO; JPO; DERWENT	OR	ON	2006/04/02 13:18
S13 7	2514	(coating same method) and (silica same temperature same second)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:20
S13 8	2163	(coating same method) and (silica same temperature same second)and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:21
S13 9	2163	((coating same method)".ti") and (silica same temperature same second)and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:22
S14 0	1362	((coating with method)".ti") and (silica same temperature same second)and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:25
S14 1	214	((coating with method)".ti") and (silica same (colloid colloidal) same temperature same second)and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:26

## EAST Search History

S14 2	9	((coating and method).ti.) and (silica same (colloid colloidal) same temperature same second)and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:30
S14 3	12	((coating and method).ti.) and ((silicon adj dioxide) same (colloid colloidal)) and (temperature same second) and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:46
S14 4	5	((coating and method).ti.) and ((silicon adj dioxide) same (colloid colloidal)) and (bath same immersion saame voltage) and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:49
S14 5	1	((coating and method).ti.) and ((silicon adj dioxide) same (colloid colloidal)) and (bath same immersion same voltage) and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:50
S14 6	1	((coating and method).ti.) and ((silicon adj dioxide) same (colloid colloidal)) and (bath same voltage) and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 11:50
S14 7	6	((coating and method).ti.) and (silica same (colloid colloidal)) and (bath same voltage) and @ad<"20031107"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 14:13
S14 8	1443	silica with (metallic adj oxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2006/07/05 14:19
S14 9	308	(445/58).CCLS.	US-PGPUB; USPAT	OR	OFF	2006/07/05 14:20
S15 0	1307	(427/126.1,117,452).CCLS.	US-PGPUB; USPAT	OR	OFF	2006/07/05 14:20